

Attorney Docket No. 081468-0306368
Client Reference: P-0128.012-US

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: JASPER, Johannes Christiaan Maria
LOOPSTRA, Erik Roelof
MODDERMAN, Theodorus Marinus
NIJMEIJER, Gerrit Johannes
VAN ASTEN, Nicholaas Antonius Allegondus Johannes
HEUTS, Frederik Theodorus Elisabeth
GEMEN, Jacobus
DU CROO DE JONGH, Richard Johan Hendrik
BOONMAN, Marcus Emile Joannes
KLINKHAMER, Jacob Frederik Friso
CASTENMILLER, Thomas Josephus Maria

Application No.:	TO BE ASSIGNED	Confirmation No.:
Filed:	October 17, 2003	Group No.:
		Examiner
For:	OFF-AXIS LEVELLING IN LITHOGRAPHIC PROJECTION APPARATUS	

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

APPLICATION DATA SHEET
37 C.F.R. § 1.76

BIBLIOGRAPHIC DATA

1. Applicant information

First applicant: JASPER, Johannes Christiaan Maria
Citizenship: The Netherlands
Residence: Spookjesberg 33, NL-5508 EA Veldhoven, The Netherlands

Second applicant: LOOPSTRA, Erik Roelof
Citizenship: The Netherlands
Residence: Atlas 7, NL-5591 PJ Heeze, The Netherlands

Third applicant: MODDERMAN, Theodorus Marinus
Citizenship: The Netherlands
Residence: Vredehof NL-5671 DS Nuenen, The Netherlands

Fourth applicant: NIJMEIJER, Gerrit Johannes
Citizenship: The Netherlands
Residence: Boschdijk 414, NL-5622 PC Eindhoven, The Netherlands

Fifth applicant: VAN ASTEN, Nicholaas Antonius Allegondus Johannes
Citizenship: The Netherlands
Residence: Catherinastraat 20C, NL-4811 XH Breda, The Netherlands

Sixth applicant: HEUTS, Frederik Theodorus Elisabeth
Citizenship: The Netherlands
Residence: Generaal Stedmanstraat 182, NL-5623 HZ Eindhoven, The Netherlands

Seventh applicant: GEMEN, Jacobus
Citizenship: The Netherlands
Residence: De Wagenmaker 2, NL-5506 CS Veldhoven, The Netherlands

Eight applicant: DU CROO DE JONGH, Richard Johan Hendrik
Citizenship: The Netherlands
Residence: Roeklaan 16, NL-5613 EG Eindhoven, The Netherlands

Ninth applicant: BOONMAN, Marcus Emile Joannes
Citizenship: The Netherlands
Residence: Koekelberg 15, NL-5508 GA Veldhoven, The Netherlands

Tenth applicant: KLINKHAMER, Jacob Frederik Friso
Citizenship: The Netherlands
Residence: Houthaak 14, NL-2611 LE Delft, The Netherlands

Eleventh applicant: CASTENMILLER, Thomas Josephus Maria
Citizenship: The Netherlands
Residence: Sophia van Wurtemberglaan 48, NL-5616 BR Eindhoven, The Netherlands

2. Correspondence information

Correspondence for this application should be addressed as follows:

Customer No.: 00909

3. Application information

Title of Invention: OFF-AXIS LEVELLING IN LITHOGRAPHIC
PROJECTION APPARATUS

Docket number assigned to this application: 081468-0306368

Suggested Classification: Class:

Subclass:

Technology Center to which subject matter is assigned:

Total number of drawing sheets: 9

Type of application:

Utility

Application is to be published. Suggested drawing figure for publication: FIGURE 8

Secrecy order under § 5.2:

This application does not disclose subject matter of an application which is under a secrecy order pursuant to § 5.2.

4. Representative information

The following have a power of attorney or authorization of agent in this application:

Customer No.: 00909

5. Domestic Priority information

Domestic priority for this application is claimed as follows:

35 U.S.C. § 120:

Application No.: 09/519,875

Filed: March 6, 2000

Status: PENDING

6. Foreign priority information

Foreign priority is claimed for this application as follows:

Country: EUROPE

Application No.: 99200649.4

Filing Date: March 8, 1999

7. Assignee information

The assignee(s) of this application is/are:

ASML NETHERLANDS B.V.

De Run 1110, NL-5503, LA Veldhoven, The Netherlands

Extent of interest of assignee in application: ENTIRE RIGHT, TITLE AND INTEREST

Date: 10/17/03

PILLSBURY WINTHROP LLP
P.O. Box 10500
McLean, VA 22102
Tel. No.: (703) 905-2159

Customer No.: 00909



Signature of Practitioner

Robert C. Perez

Reg. No.: 39328